## Effect of Polyethylene Glycol on the Fabrication of Nanostructured BiVO<sub>4</sub> Photoanodes for Photoelectrochemical **TEMPO-Mediated Oxidations**

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## Introduction

Bismuth Vanadate (BIVO<sub>4</sub>) is a promising semiconductor for solar energy conversion. Due to its non-toxic properties and ability to absorb in the visible light spectrum. BiVO<sub>4</sub> is of interest as an alternative to common silicon-based semiconductors. BiVO4 offers an optimal band gap to perform water oxidation for hydrogen fuel production applications. This work focuses on the oxidation of the redox mediator, 2,2,6,6tetramethylpiperidin-1-yl)oxyl (TEMPO), to aid in oxidation of potential substrates for H<sub>2</sub> production. In this study, we examine the oxidative performance of BiVO<sub>4</sub> photoanodes under varying concentrations of the structure-directing polymer, Polyethylene glycol (PEG). PEG is a useful agent in altering film thickness, porosity, and surface area. Morphology and optical measurements were completed using FESEM and UV-Vis Spectrophotometry to understand effects of PEG on BiVO<sub>4</sub> deposition. Photoelectrochemical measurements using Linear Sweep Voltammetry and Chronoamperometry were utilized to measure resultant TEMPO oxidation.



PEC cell set up with BiVO<sub>4</sub> photoanode



## **Research Method**





A. Optical image of photoanode with epoxy layer. B. Top view of BiVO4 interface magnified 45,000x. C. Cross-section view of interface magnified at 16,000x with markers indicating deposition thickness



A. Optical image of photoanode without epoxy layer. B. Top view of  $BiVO_4$  interface magnified 40,000x. C. Cross-section view of interface magnified at 17,000x with markers indicating deposition thickness.





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